An ultra sensitive radio frequency single electron transistor working up to 4.2 K

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A bstract

W e present the fabrication and m easurem ent of a radio frequency single electron transistor (rf-SET), that displays a very high charge sensitivity of 1:9 e/ p H z at 42 K. At 40 m K, the charge sensitivity is 0:9 and 1:0 e/ p H z in the superconducting and norm all state respectively. The sensitivity was measured as a function of radio frequency amplitude at three di erent temperatures; 40 m K, 1:8 K and 42 K.

The radio frequency single electron transistor (rf-SET) is the most sensitive detector of charge to date. Unlike the conventional single electron transistor (SET), it is not bandwidth lim ited by the resistance-capacitance product of the SET resistance and the parasitic lead capacitance. Typically the rf-SET displays high bandwidth, 10 M H z, in combination with a charge resolution of the order of 10 ⁵ e/ $\overset{'}{H}$ z. A lthough the conventional SET is theoretically more sensitive than the rf-SET [1], the rf-SET can operate at frequencies where 1/f noise is negligible, which makes the rf-SET more sensitive in experimental conditions. The improved band width and charge sensitivity have made the rf-SET a good choice when m easuring solid state charge qubits [2] [3], charging of quantum dots [4] and single electron transport [5] [6]. In rfm easurem ents of the SET, the im pedance of the SET is matched to the characteristic im pedance of a co-axial cable by a resonance circuit. The di culty of making a tank circuit with a high Q -value as well as a high operating frequency makes rfm easurement of a SET practical only when the SET is relatively low ohm ic. Therefore, SET resistances in the range 20 to 200 k are desirable. A sthe tunnel junctions are m ade sm aller the charging energy ($E_{\rm C}$) increases, which increases both the charge sensitivity of the SET and the maximum operating tem perature. How ever, since the tunnel resistance is inversely proportional to the junction area, this also increases the resistance, and eventually the resistance becom es too large for rf-SET operation. W ith conventional alum inum angle evaporation, it has been di cult to make tunnel junctions smaller than 100 $\,$ 100 $\,$ nm² (E $_{\rm C}$ 1K) without increasing the device resistance too much. Hence, the operating tem perature range of the rf-SET has been limited to roughly a few hundered mK.By using low oxidation pressure [7] we here show that it is possible to combine high $E_{\rm C}$ with rfoperation. There are num erous experiments that require the bandwidth and sensitivity of the rf-SET, and are therefore perform ed at m illikelvin tem peratures. W ith a higher operating tem perature of the rf-SET, many of these experiments could also be conducted at 42 K.O ther experiments now use conventional SETs with a higher charging energy, and also resistance, to enable m easurem ents at

higher tem peratures. By switching to a rf-SET operating at 4.2 K som e of these experiments, such as electron counting [6] and the scanning-SET [8], could gain in sensitivity and bandwidth.

In this letter, we describe the measurem ent of a rf-SET working from 40 m K to 42K of the order of 1 $e^{p}\overline{H~z}$

The SET was fabricated with 2-angle evaporation of alum inum on SiO₂ and in situ oxidation. The details are described in [7]. In the fabrication a very low oxidation pressure was used, which resulted in very thin tunnel barriers. Since the tunnel resistance depends exponentially on the barrier thickness, this improved the speci c conductance of the barriers without increasing the speci c capacitance. The data presented here are taken on a device which had an asymptotic serial tunnel resistance R = 25 k, in spite of its very sm all size (see qure 1). The relatively low resistance made strong tunneling contributions sizable. The e ect of this was two fold. First, the Coulomb diam onds were sm eared due to strong tunneling, even at low tem perature, which m ade it di cult to t asymptotes to the Coulomb diam ond edges and hence to determ ine the charging energy (E $_{\rm C}$). Second, the nom inal E $_{\rm C}$ (as determ ined of the total island capacitance) of the SET was lowered to an elective $E_{\rm C}$ [9]. The charging energy of the SET was estim ated by thing asymptotes to the coulom b diam ond (see gure 3b) and the resulting charging energy was $E_c = 18 - 2 K$, which corresponds to a total island capacitance C = 58 aF. One junction capacitance was slightly larger than the other, 33 aF com pared to 25 aF, which indicates that the geom etrical sym m etry of the SET was good.

The experimental SET up is depicted in g.1. Various liters are not shown to simplify the gure. The rf signal is transmitted from room temperature via a directional coupler at 4.2 K, and is receted at the combined SET/tank circuit. At resonance, the receted power depends on the resistance of the SET and the tank circuit parameters, i.e. $P_R = P_A = 1 = 4Q \frac{2}{R_d} = [10]$, where P_R , P_A , Q are the receted rf power, the applied rf power and the Q-value of the tank circuit. Z_0 and R_d denote the characteristic in pedance of coaxial cable connected to the tank circuit and the resistance of the SET respectively. In our set up, the Q-value was approximately 11:6 and the characteristic impedance was 50. To measure the charge sensitivity of the SET, we proceeded as in [11]. The SET was excited with a 1:5 M H z gate voltage which amplitude modulates the carrier frequency (345 M H z) and produces sidebands in the frequency spectrum of the released rf signal. The sidebands and main frequency can be seen in the upper inset in gure 2. The sensitivity of the SET is then calculated by comparing the height of the side band peak with the noise oor, i.e. the signal to noise ratio. The sensitivity Q, is:

$$Q = \frac{q_{\rm rm \ s}}{p_{\frac{10^{\rm S \ N \ R}}{2B}}}$$
(1)

Here, $q_{rm s}$ is the applied root mean square gate charge, B is the resolution bandwidth and SNR is the signal to noise ratio in dB. The additional factor p - 2 in the denominator as compared to [11], includes the contributions from both sidebands since information can be extracted by homodyne mixing from both sidebands. We measured the sensitivity for dimentification of the sensitivity for dimensional factor each rf amplitude we varied V_{SD} and V_g to model to not be determined to the sensitive that the temperatures 4.2, 1.8 and 40 mK.

At 4.2 K, the best SNR was 22.88 dB, $q_{rm s} 0.0044 e_{rm s}$ and B was 15 kH z, which results in a sensitivity of 1.9 0.1 e/ p H z. The current voltage characteristics shown in gure 2 display a large modulation of approximately 20 nA of the source drain current (I_{SD}) with respect to the gate voltage (V_g), despite the relatively high temperature. It is clear that rf operation of the SET should be possible. In the lower inset of gure 2, the rejected power is plotted as a function of V_g and V_{SD}, where the highest signal to noise ratio is achieved close to zero bias. A closer inspection shows that this maximum was achieved with V_{SD} = 0.05 mV, i.e. near a pure rfm ode [11] m easurem ent. The optim um sensitivity in the pure rfm ode has been calculated by K orotkov and Paalanen [1]:

$$Q = 2.65e (R C)^{1=2} k_B TC = e^{2} e^{1=2}$$
 (2)

where k_B and T stand for the Boltzm an constant and absolute temperature. If the total capacitance and resistance of the measured SET is used, this formula results in a maximum theoretical sensitivity of $12 \text{ e/}^{p} \frac{p}{\text{Hz}}$ at 42 K. The charge sensitivity is therefore approximately 1.6 times worse than the theoretical minimum.

At 40 m K (see qure 3), the sensitivity in proved approximately by factor of 0:1 e Hz. Several two. In the superconducting case, the sensitivity was 0.9factors contributes to the uncertainty. The spectrum analyzer has an accuracy better than 0.01 dB, and calibrating the voltage necessary to induce 1 $e_{\rm rm\ s}$ on the gate has an uncertainty of approximately 4 %. In addition to these system atic errors, the gate bias points can vary due to uctuating charges in the vicinity of the SET. Two consecutive measurements separated by 24 hours resulted in two nearly equal maximum sensitivities (0.85 and 0.88 e/ P H z in the superconducting state). The combined uncertainty is 7%. The sensitivity in the norm alcase was 1:0 0:1 e/Hz, and in both the superconducting and the norm alstate case the V_{SD} was sm allat the optimum bias point; 0:1 m V.At this tem perature, how ever, the theoretical maximum sensitivity is roughly ve times better than what we measured. A plot of the shot noise of the SET as a function of current (see gure 3a) with the SET at 40 mK and in the norm al state, shows that the noise tem perature (T $_{\rm n}$) of the ampli erclearly contributes. T_n is approximately 10 K referred to the tank circuit, i.e. substantially higher than the nom inal noise tem perature of the ampli er alone, which is 2 K. In the charge sensitivity measurements we used a resolution bandwidth of 15 kHz, which translates the noise tem perature to a 92 dBm noise oor. This level co-insides with the noise oor of the 40 mK sensitivity measurements, i.e. the sensitivity is degraded by the ampli er noise. Self heating of the SET, which grows larger with a sm aller SET, could also lim it the perform ance of the SET in the 40 mK measurements. Since the applied voltage is large and the island is very small (see gure 1), the electron temperature may well be of the order of1K.

5

In gure 4, we see how the charge sensitivity depends on the applied rf signal for the measurements at 40 mK, 1.8 K and 42 K. For each of these rf amplitudes, V_{SD} and V_{g} has been optimized to ind the best sensitivity. As seen in gure 4, the maximum sensitivity is found at rf amplitudes 82.5 dBm (40 mK, superconducting state), 77.5 dBm (40 mK, normal state), 80.5 dBm (1.8 K, normal state) and 72.5 dBm (42 K).

The SET reported here had a 5 6 times larger E_c compared to the sample in [11], but lower tunnel resistance. As shown by Korotkov and Paalanen, the size of the optimum of signal increases with increasing E_c [1]. Therefore, we could apply a larger of signal and still cover a part of the coulomb diam ond where dI_{5D} / dV_g was large. The applied of signal was between 12.5 (at 40 m K, superconducting state) and 17.5 (4.2 K) dB larger than in [11]. This yielded a better signal to noise ratio, even when the higher noise temperature of the ampli er compared to [11] has been taken into account, and hence a better charge sensitivity. U sing the modi ed sensitivity formula (1), the sensitivity of the previously best reported result [11] is 2:3 e/^P H z, which should be compared to our sensitivities: 1:9 e/^P H z (at 4.2 K), 1:0 e/^P H z (40 m K, normal state SET) and 0:9 e/^P H z (40 m K, superconducting SET).

In sum m ary, we have m easured a charge sensitivity for a rf-SET that is better than the previously best reported value both at 40 m K, and at 42 K. This is due to high charging energy and low tunnel resistance. The higher operating tem perature of this device m akes it possible to perform rf-SET m easurements at 42 K rather than at m K tem peratures.

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Caption gure 1

The schematics of the rfm easuremtent. Filters are not shown. The inset in the top right corner shows an scanning electron microscope image of the SET, with the exception of the gate electrode. \T',\S'' and \D'' stand for island, source and drain respectively. The scale bar is 100 nm

Caption gure 2

(Cobr online). M easurements at 42 K. The current-voltage characteristics, I_{SD} as a function of V_{SD} for various V_g voltages. In the upper left inset, the rejected power (RP) as a function of frequency is shown. The two sidebands are situated 1.5 M Hz to the left and right of the main frequency. The lower right inset is a color plot of the signal to noise ratio of the side bands as a function of V_{SD} and V_g .

Caption gure 3

(C olor online). Measurements at 40 mK with the SET in the superconducting state. a). The current-voltage characteristics, for various V_g. In the upper left inset, the shot noise of the SET as a function of I_{SD} where the noise is collected in a 8 M Hz span at the output of the cold am pli ers. The two asymptotes intersect at the am pli er noise contribution, which is estimated to 10 K. In the lower right inset the signal to noise ratio of the sideband, measured in dB, is plotted as a function of V_{SD} and V_g. The mark \x" shows the optimum bias point for P_i= 102:5 dBm, and the dotted circle marks the optimum bias point for P_i= 82:5 dBm . P_i signi es the power of the incident rf signal at the tank circuit. b) The rejected power of the tank circuit as a function of V_{SD} and V_g. The dotted diam ond, with $E_c = 18$ 2K

Caption gure 4

(Color online). The sensitivities as a function of the applied rf power at the tank circuit for three di erent tem peratures.

Figure 1, author H.Brenning

Figure 2, author H.Brenning

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Figure 4, author H.Brenning

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